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Listing of Claims:

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1. (Currently amended) A front-end array process for making a liquid crystal display panel, comprising:

depositing a molybdenum-containing metal layer on a glass substrate;

- forming a patterned photoresist-and-defining a gate and word-line array pattern on said molybdenum-containing metal layer, wherein said patterned photoresist defines a gate and word line array pattern; and
 - using said patterned photoresist as an etching-hard mask, uniformly etching said molybdenum-containing metal layer to form said gate and word line array pattern having elightly substantially oblique sidewalls, wherein said etching of said molybdenum-containing metal layer uses gas mixture.
 - 2. (Original) The front-end array process for making a liquid crystal display panel according to claim 1 wherein after said etching of said molybdenum-containing metal layer, an over etching is carried out.
 - 3. (Currently amended) The front-end array process for making a liquid crystal display panel according to claim 1 wherein—oxygen/fluorine_fluorine/oxygen containing gas mixture is SF_6/O_2 having a ratio of about 700sccm/300sccm.
 - 4. (Original) The front-end array process for making a liquid crystal display panel according to claim 1 wherein said etching of said molybdenum-containing metal layer is executed under a process pressure higher than 25 mTorr.
- 5. (Original) The front-end array process for making a liquid crystal display panel according to claim 1 wherein said etching of said molybdenum-containing metal layer is further controlled by a source power, a bias power, process pressure, oxygen flowrate and flowrate of fluorine containing gas.

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6. (Original) The front-end array process for making a liquid crystal display panel according to claim 1 wherein said molybdenum-containing metal layer is a dual-metal layer.

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- 7. (Currently amended) The front-end array process for making a liquid crystal display panel according to claim 6 wherein said dual-metal layer is Mo/AlNd, MoW/AlNd, or MoW/Al, wherein Mo and MoW are top layers, while AlNd and Al are bottom layers.
- 8. (Original) The front-end array process for making a liquid crystal display panel according to claim 1 wherein said etching of said molybdenum-containing metal layer is detected by an end-point detection method at an wavelength of about 704nm.
- (Original) The front-end array process for making a liquid crystal display panel
 according to claim 1 wherein said gas mixture is oxygen/fluorine containing.
 - 10. (Original) The front-end array process for making a liquid crystal display panel according to claim 1 wherein said gas mixture is oxygen/chlorine containing.
- 20 11. (Original) The front-end array process for making a liquid crystal display panel according to claim 1 wherein said gas mixture is oxygen/chlorine/fluorine containing.
- 12. (Original) The front-end array process for making a liquid crystal display panel
 according to claim 1 wherein said gas mixture is SiF₆/O₂ containing.
 - 13. (Original) A front-end array process for making a liquid crystal display panel, comprising:

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depositing a molybdenum-containing metal layer on a glass substrate; forming a patterned photoresist and defining a gate and word line array pattern on said molybdenum-containing metal layer; and etching said molybdenum-containing metal layer by said patterned photoresist to form said gate and word line array pattern.

14. (Currently amended) The front-end array process for making a liquid crystal display panel according to claim 13 wherein said gate and word line array pattern have slightly substantially oblique sidewalls.

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- 15. (Original) The front-end array process for making a liquid crystal display panel according to claim 13 wherein after said etching of said molybdenum-containing metal layer, an over etching is carried out.
- 16. (Currently amended) The front-end array process for making a liquid crystal display panel according to claim 13 wherein-oxygen/fluorine fluorine/oxygen containing gas mixture is SF₆/O₂ having a ratio of about 700sccm/300sccm.
- 17. (Original) The front-end array process for making a liquid crystal display panel
 according to claim 13 wherein said etching of said molybdenum-containing metal
 layer is executed under a process pressure higher than 25 mTorr.
 - 18. (Original) The front-end array process for making a liquid crystal display panel according to claim 13 wherein said etching of said molybdenum-containing metal layer is detected by an end-point detection method at an wavelength of about 704nm.
 - 19. (Original) The front-end array process for making a liquid crystal display panel according to claim 13 wherein said molybdenum-containing metal layer is a

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dual-metal layer.

layers.

20. (Currently amended) The front-end array process for making a liquid crystal display panel according to claim 19 wherein said dual-metal layer is Mo/AlNd, MoW/AlNd, or MoW/Al, wherein Mo and MoW are top layers, while AlNd and Al are bottom

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